

# UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/650,181	08/27/2003	Masayuki Ohta	259052003300	6464	
25226 MORRISON &	7590 05/24/2007 & FOERSTER LLP		EXAM	INER	
755 PAGE MI	LL RD		VAN ROY, TO	VAN ROY, TOD THOMAS	
PALO ALTO,	CA 94304-1018		ART UNIT	PAPER NUMBER	
•		,	2828	,	
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			MAIL DATE	DELIVERY MODE	
			05/24/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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	Application No.	Applicant(s)	
	10/650,181	OHTA ET AL.	
Office Action Summary	Examiner	Art Unit	
·	Tod T. Van Roy	2828	
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with	the correspondence address -	•
A SHORTENED STATUTORY PERIOD FOR REI THE MAILING DATE OF THIS COMMUNICATION  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a  - If NO period for reply is specified above, the maximum statutory peri  - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a repreply within the statutory minimum of thirty (iod will apply and will expire SIX (6) MONTHUM, cause the application to become ABA	ly be timely filed  30) days will be considered timely.  IS from the mailing date of this communication  NDONED (35 U.S.C. § 133).	ation.
Status			
1) ■ Responsive to communication(s) filed on 19 2a) ■ This action is FINAL. 2b) ■ T  3) ■ Since this application is in condition for allow closed in accordance with the practice under	his action is non-final.  wance except for formal matter	•	s is
Disposition of Claims			•
4) ⊠ Claim(s) 1,5 and 10-15 is/are pending in the 4a) Of the above claim(s) is/are without 5) □ Claim(s) is/are allowed.  6) ⊠ Claim(s) 1,5,10-15 is/are rejected.  7) □ Claim(s) is/are objected to.  8) □ Claim(s) are subject to restriction and	drawn from consideration.		
Application Papers			
9) The specification is objected to by the Exam 10) The drawing(s) filed on is/are: a) a Applicant may not request that any objection to to Replacement drawing sheet(s) including the cort 11) The oath or declaration is objected to by the	accepted or b) objected to by the drawing(s) be held in abeyance rection is required if the drawing(s)	e. See 37 CFR 1.85(a). ) is objected to. See 37 CFR 1.12	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for fore  a) All b) Some * c) None of:  1. Certified copies of the priority docume  2. Certified copies of the priority docume  3. Copies of the certified copies of the papplication from the International Bur  * See the attached detailed Office action for a	ents have been received. ents have been received in Appriority documents have been received in Receive	olication No eceived in this National Stage	
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB.	Paper No(s)/	mmary (PTO-413) Mail Date ormal Patent Application (PTO-152)	
Paper No(s)/Mail Date	6)  Other:	•	

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

### **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 03/19/2007 has been entered.

## Response to Amendment

The examiner acknowledges the amending of claims 1 and 5.

## Response to Arguments

Applicant's arguments with respect to claims 1 and 5 have been considered but are most in view of the new ground(s) of rejection.

Please see the enclosed enlarged fig.1 of Sugano in reference to the proceeding remarks.

The examiner makes note that in the preceding final office action the Sugano reference was used to show a number of marker elements that were separated via a dashed line. The examiner did not comment on the dashed line being a physical line existing on the device surface, nor did the rejection require a line of that type to exist. The applicant's statement that the examiner assumed this line to be physically present in order to make the rejection is not correct.

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Please see below for an updated rejection to the claims.

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

Claims 1, 5, and 10-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sugano (JP 63136687) in view of Goto (2002/001327).

With respect to claim 1, Sugano teaches a method for manufacturing a semiconductor laser device, comprising the steps of: forming electrode patterns arranged in a plurality of rows (fig.1) extending in a first direction (top to bottom of figure) on an upper surface of a semiconductor wafer having at least a light emission layer (fig.3 #3), the electrode patterns having opposed to two edges extending in the first direction (left and right sides of dashed electrode patterns); cutting the resultant

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semiconductor wafer for a predetermined width to yield a plurality of semiconductor bars (abs.), and sectioning the semiconductor bars in desired sizes to form semiconductor laser devices each having a pair of cleavage surfaces (cleaved along dotted line), the surfaces being parallel to a second direction and distant from each other by a resonator length (abs., fig.1 L's), wherein the formed electrode patterns are continuous with each other in the first direction (fig.1), each electrode pattern including a series of markers having a periodical pattern (markers are the "C' gaps in the electrode patterns, series of markers forms periodical pattern) which is continuous one marker to the next in the first direction, the markers being formed on one or both of the edges of the electrode patterns (each formed on an edge on either side of the electrode pattern), and a minimum unit of the periodical pattern has an overall length in the first direction equal to L/n and not greater than the resonator length (marker not greater than resonator length L), wherein L is the resonator length and n is a positive real number not smaller than one, the first direction being a direction along the resonator length, the second direction being perpendicular to the first direction and each laser device being cut or sectioned to have a length which is an integral multiple of the length of a marker (abs., marker is 1\*L). Sugano does not teach the markers to be asymmetric in shaped when bisected in the chip width direction. Goto teaches the used of markers wherein one side of the electrode pattern is asymmetric relative to the other (fig.5, indented shoulder portion near arrow 19a). It would have been obvious to one of ordinary skill in the art at the time of the invention to combine the electrode pattern of Sugano with the asymmetric electrode pattern of Goto in order to distinguish forward and backward device directions

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(Goto, [0028], which when added to Sugano would create asymmetric markers when bisected in a chip width direction).

With respect to claim 5, Sugano teaches a semiconductor laser device, comprising: a semiconductor layer portion including at least a light emission layer (fig.3 #3) and a pair of cleavage surfaces the surfaces being parallel and distant from each other by a resonator length (fig.1 cleaved along dotted line); and an electrode pattern piece formed on an upper surface of the semiconductor layer portion (fig.1 dashed lines), the electrode pattern piece having opposed two first edges extending in a first direction (fig.1 top and bottom) and opposed two second edges extending in a second direction along the pair of cleavage surfaces (fig.1 left and right), wherein the two second edges come in contact with the pair of cleavage surfaces (fig.1 cleaved along dotted line, so in contact with the surface), each electrode pattern piece including a series of markers having a periodical pattern formed on one or both of the first edges (markers are the "C' gaps in the electrode patterns, series of markers forms periodical pattern, each formed on an edge on either side of the electrode pattern), a minimum unit of the periodical pattern having an overall length in the resonator length direction equal to L/n and not greater than a resonator length, wherein L is the resonator length and n is a positive number not smaller than 1 (markers not greater than resonator length), the first direction being a direction along the resonator length, wherein the markers can be used to form laser chips of different resonator lengths. Sugano does not teach the markers to be asymmetric in shaped when bisected in the chip width direction. Goto teaches the used of markers wherein one side of the electrode pattern is

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asymmetric relative to the other (fig.5, indented shoulder portion near arrow 19a). It would have been obvious to one of ordinary skill in the art at the time of the invention to combine the electrode pattern of Sugano with the asymmetric electrode pattern of Goto in order to distinguish forward and backward device directions (Goto, [0028], which when added to Sugano would create asymmetric markers when bisected in a chip width direction).

With respect to claim 10, Sugano teaches the marker length is between 1/5 and 5 times the width (fig.1 length approx. 2 times the width).

With respect to claim 11, Sugano teaches the wafer is cut in predetermined widths to yield a plurality of semiconductor bars extending in the resonator length direction, and the plurality of semiconductor bars are cut in predetermined resonator lengths (fig.1, abs.)

With respect to claim 12, Sugano teaches the ability to cut the semiconductor bars into different resonator lengths, yielding a plurality of different semiconductor laser devices (abs.).

With respect to claim 13, Sugano teaches one of the semiconductor bars is cut in integral multiple lengths of the overall length of the marker (abs.).

Claims 14-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sugano and Goto in view of Ohbuchi (US 6611542).

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With respect to claims 14-15, Sugano and Goto teach the semiconductor laser device as outlined in the rejection to claim 5, but do not teach the markers to be shaped like the teeth of a saw or an isosceles triangle. Ohbuchi teaches a semiconductor laser device with electrode markers wherein it is taught that markers are of an isosceles triangle, or saw tooth, shape (fig.1). It would have been obvious to one of ordinary skill in the art at the time of the invention to replace the rectangular markers of Sugano and Goto with the isosceles, saw tooth, markers of Ohbuchi as a matter of engineering design choice, since the shape of the marker is not crucial, only that it has distinguishable dimensions (Ohbuchi, col.8 lines 12-14, col.3 lines 39-45).

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tod T. Van Roy whose telephone number is (571)272-8447. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Minsun Harvey can be reached on (571)272-1835. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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